



5th Workshop on LHCb upgrade II

30 .03 - 01 .04. 2020 Barcelona

Cooling, Detector Layout and Mechanics

Oscar Augusto on behalf of the LHCb VELO group

Cooling

Module cooling

- Target coolant temperature below -40C
- Evaporative CO2 cooling is reaching its limit (triple-point at -56C)
- New coolants R&D needed: N2O(-163.65), CF4(-184C), Krypton(-157.4C)

Cooling plate manufacturing

- Silicon microchannels vs 3D-printing
- Cooling performance, CTE mistmatch, tile attachment, reproducibility
- Materials: Titanium, Ceramics, ...



	Si	Al	Ti	SiC
Thermal cond. (W/m.K)	149	237	6.8	120
Thermal Exp. (ppm/K)	2.6	23.1	8.9	2.8
Density (g/cm ³)	2.3	2.7	4.4	3.2

Microchannels etched in silicon



- Narrow restrictions at the entrance
- 60 µm x 60 µm (40 mm long)
- Prevents instabilities among the channels
- Main channels
- 120 μm x 200 μm (~260 mm in average)
- Heat provided by electronics is absorbed by the CO₂ changing the ratio of gas/liquid
- Advantages: High cooling performance, no CTE mismatch to the silicon sensors/ASICs, homogeneous and low mass
- Disadvantages: production cost, CTE mismatch to Hybrids (kapton) mechanically more fragile and integration

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Wirebonds



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Microchannels	Silicon
Reusability	N62 Gigatracker
Hybrid Cooling plate	Adhesive 3M 9461P 100 30 µm no curing required
india	REWORKABILITY The detector can be detached from the cooling plate or the other way around.

Alessandro Mapelli, Vertex 2017

Integration

Improved soldering process



3D printing connectors or mold



Marcel Vos, Forum on tracker mechanics, Cornell University, June 2019

Microchannels Silicon

Production cost1)Alternative Bonding (Anodic bonding, ...)2)Smaller cooling plates



Buried microchannels

CMOS compatible process Holds 110 bars Demonstrator expected soon AIDA-2020-NOTE-2020-003



Most ambitious approach: bring the cooling to the tiles R&D @ CPPM

- 1)Laser etching and anodic bonding
- 2)5 x 10 channels per wafer
- 3)200µm x 70µm x 4.5cm per channel
- 4)Next step: connector with anodic bonding





Ti 3D printing

- Material: grade 2 Ti
- Easier to handle (compared to Si)
- Easy to weld
- Cheap (~250 EUR excluding welding)
- Fast turnaround for design changes (few weeks)
- Fast production: 25/batch, 1 batch/ few days
- Restrictions can be integrated in the inlet (0.35 mm x 0.35 mm x 40 mm)





Ti 3D printing

Integrated restriction for flow stability

 a) down to 200 μm

 High pressure test (up to 250 bar)
 Leak tight (at least 250 μm wall)

 Deflection due to temperature variations

 100 μm

 Better CTE mismatch to the Hybrids





Disadvantages:
1) Low thermal conductivity (16 W/m K)
2) CTE mismatch (6 ppm/K) to Silicon / Glue Corresponds to ~14 um variation for Upgrade I
3) Reproducibility

Oscar Augusto

Modules geometry



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Modules geometry





"To be, or not to be, that is the question" Foil or no foil

Foil or no foil

- No foil is better for the physics performance
 - Major contribution to the material budget for the VELO Upgrade I
- Module might come closer to the beam (better performance) or profit from the improved performance and move away to reduce radiation damage
- Critical for the design constraints and module replaceability. Radiation hardness changes:
 - 10¹⁶ neq/cm² (replaceable) vs 10¹⁷ neq/cm² (non-replaceable)
- A few ideas:
 - Ultra thin foil supported by the modules
 - Wires weave



Piston and wires concept



- 1) Detector is in beam vacuum
- 2) The image current travels through the foil replacement
- 3) Wires weaver
 - (a)Tungesten-Rhenium gold plated?(b)Coated carbon fiber strips or tube?

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 - (b)Coated carbon fiber strips or tube?
- 4) The detector is fully supported by a mountable leak tight detector box structure (a)A spare would allow guicker replacement
- 5) The region below the module base has its own volume
 - (a)Outgassing from cables and additional electronics (OPB?) are isolated from the beam vacuum
 - (b)Cooling through dry-air flushing
 - (c)Cooling provided through the box
- 6) Single detector port

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- 7) When beams are stable
 - (a)Piston is retracted
 - (b)Detector halves come closer to the beam

Conclusion

- 3D printing is very attractive
 - Cost effective for replaceable modules and design flexibility
 - Titanium is not the only option (Alumina, SiC, ...)
- Microchannels in silicon are not excluded
 - re-usability and/or cost reduction will be crucial
- Foil or No foil decision has critical implications for the design and module replaceability and mechanics
- New ideas are welcome even the crazy ones... :)

Backup slides

Micro-cooling @ CPPM

Gregory Hallewell Julien Cogan Mathieu Perrin-Terrin Olivier Leroy Stéphan Beurthey

March 2020

Laser etching

1st experience with micro-channels :

- laser etching of 2 4"-silicon wafers
 - 5x10 channels per wafer
 - 200µm x 70µm x 4.5cm per channel
 - pass-through holes at each channel end
 - with CNRS/LP3 lab, Marseille
- anodic bonding of glass wafer (500 µm thick)
 - with Alessandro Mapelli at EPFL
- thermal and flow tests
 - water circulated at a controlled temperature and flow rate
 - microchannel chips heated with a kapton heater
- good for prototyping but probably too slow and not cheap enough for production







Plans

On going: anodic bonding of Si wafers with a thin intermediate layer of glass

- 5 4"-Si wafers etched via DRIE
 - single-ended micro-channel for pressure test with various geometries
 - design compliant with pressure test bench used at CERN
- bonded in Germany
- currently on hold, next:
- thinning and dicing
- pressure test @ CPPM

Next, if previous step is successful: start R&D on connector anodic bonding